Controlling Half-Metallicity of Graphene Nanoribbons by Using a Ferroelectric Yea-Lee Lee,[†] Seungchul Kim,[†] Changwon Park,[†] Jisoon Ihm,^{†,*} and Young-Woo Son^{‡,*} [†]Department of Physics and Astronomy, Seoul National University, Seoul 151-747, Korea, and [‡]Korea Institute for Advanced Study, Seoul 130-722, Korea

ince graphene, a single layer of graphite, was shown to be exfoliated on the silicon oxide surface,¹ there has been many studies on its various interesting physical, chemical, and mechanical properties. Specially, its unique electronic characteristics have spurred researchers to envisage nanoelectronic circuits composed of carbon atoms only.^{2,3} To achieve nanoelectronic devices based on graphene, it should be cut into small pieces which inevitably have edges at the boundaries. Together with the finite size effects,^{4,5} nanoscale graphene fragments with these edges exhibit many different properties compared with those of two-dimensional graphene. Thus, it is important to understand the physics of the one-dimensional graphene nanostructure, that is, graphene nanoribbon (GNR).^{4,5} Among various properties of the ribbon studied,⁶⁻¹³ the magnetism of the zigzag graphene nanoribbon (ZGNR) is especially notable.^{11–13} The magnetism arises at the zigzag-shaped edges because of the localized π -orbitals of carbon atoms at the edges.^{4,11-13} Considering a quite long spin coherence length in graphene,14 the magnetism at the edges may be useful in future spintronics applications.15

Polymer

One of the most interesting properties regarding the application of the magnetism in ZGNRs¹⁶⁻²² is the electric-fieldinduced half-metallicity.¹¹ Under the transverse electric field, ZGNRs show the halfmetallicity¹¹ which originates from a unique interplay between the interedge antiferromagnetic ordering and the relative potential shift between two edges. Despite its novel feature, the required transverse electric field for the half-metallicity is too strong to be obtained easily in experiments.¹¹

ABSTRACT On the basis of first-principles computational approaches, we present a new method to drive zigzag graphene nanoribons (ZGNRs) into the half-metallic state using a ferroelectric material, poly(vinylidene fluoride) (PVDF). Owing to strong dipole moments of PVDFs, the ground state of the ZGNR becomes half-metallic when a critical coverage of PVDFs is achieved on the ZGNR. Since ferroelectric polymers are physisorbed, the direction of the dipole field in PVDFs can be rotated by relatively small external electric fields, and the switching between half-metallic and insulating states may be achieved. Our results suggest that, without excessively large external gate electric fields, half-metallic states of ZGNRs are realizable through the deposition of ferroelectric polymers and their electronic and magnetic properties are controllable via noninvasive mutual interactions.

KEYWORDS: graphene nanoribbon · half-metal · ferroelectric polymer · poly(vinylidene fluoride)

Many researchers have suggested diverse methods such as introducing quantum dots with the zigzag edges,^{16,17} functionalizing edges of ZGNRs,¹⁸⁻²⁰ and boron-nitrogen (B-N) substituting for designated carbon atoms.^{21,22} Some of these methods are successful in showing half-metallicity without external electric fields, though impractical because fine control of positions of functional groups and B-N substitution is inevitable. Moreover, the half-metallic states are hardly controllable with those proposed methods.

In this paper, we propose a method to drive the ZGNR into a half-metallic state by depositing a ferroelectric material, poly(vinylidene fluoride) (PVDF)²³ on the ZGNR. The PVDF, one of the well-known ferroelectric materials, shows strong ferroelectricity and high crystallinity.24-27

The atomic model for the PVDF is in Figure 1a. In general, two surfaces of the ferroelectric thin film, cut across the dipole moment aligned to a certain direction, cause a potential difference due to the dipole field. Likewise, several aligned PVDFs form the electric field which is induced by the dipole moments, and even a few layers show

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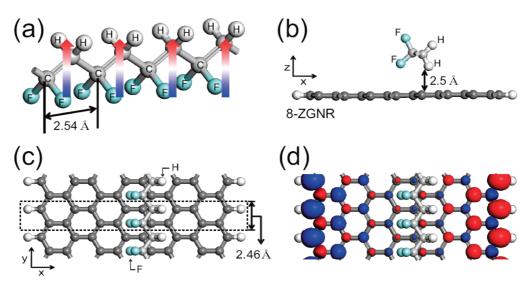


Figure 1. (a) Ball-and-stick model for poly(vinylidene fluoride) (PVDF). The arrows indicate the direction of the dipole moment (from the fluorine side to the hydrogen side). (b) Stable configuration of a PVDF chain deposited on the 8-ZGNR whose edges are passivated by hydrogen atoms. The PVDF chain and the ZGNR are set parallel along the *y*-axis. The PVDF lies flat on the ZGNR, the height from the ZGNR to the lowest atom of the PVDF is 2.5 Å, and the PVDF sits on the center of the ZGNR. (c) Top view of the same configuration as in panel b. (d) The isosurface of the charge density difference between the upspin and the down-spin ($\rho_{\uparrow}(r) - \rho_{\downarrow}(r)$) when the PVDF is deposited on the 8-ZGNR. The blue (red) region denotes the + sign (- sign) with the isovalue of 6.7 × 10⁻³ |e| Å⁻³.

a substantial ferroelectricity. Here, we show that PVDFs can weakly bind to the surface of the ZGNR, with dipole direction parallel to the surface, thereby achieving the half-metallicity without any electric field. Because of their weak binding nature, the direction of induced electric fields is controllable, and the switching between half-metallic states and antiferromagnetic insulating states are made possible by external gate fields. We also note other experiment studies exploiting the interplay between ferroelectricity of the PVDF and graphene.^{28,29}

RESULTS AND DISCUSSION

We have considered the *n*-ZGNR that has *n* units of the C-C pair in the *x*-direction per unit cell and repeats along the y-axis with the periodicity of 2.46 Å. The unit cell of the PVDF also repeats along the y-axis, but with a different equilibrium unit cell length of 2.54 Å which is 3.15% longer than that of the ZGNR (Figure 1a). For convenience, the unit cell size of the PVDF is set to be reduced in the y-direction so that it matches the length of the ZGNR (2.46 Å) in studying the joint system (Figure 1b,c). The unit cell in this system is indicated in Figure 1c. We confirm that our atomic models with the slightly compressed PVDF on the ZGNR give essentially the same results as the ones obtained from a fully relaxed geometry (without compression) in a very large commensurate unit-cell for the PVDF and the ZGNR. We will discuss this issue later. The vacuum along the x-axis is set to be longer than 70 Å in order to avoid the spurious dipole interactions between the adjacent PVDFs in repeated supercells. All properties remain the same when the supercell size is doubled, and the dipole correction is negligible for our purpose. In determining the most stable position of the PVDF on the ZGNR, three pa-

VOL. 4 • NO. 3 • LEE ET AL.

rameters have to be optimized simultaneously: directions of the dipole moment of the PVDF, heights of the PVDF from the ZGNR plane, and distances between the PVDF and the edge of the ZGNR along the *x*-axis. From a combinatorial search, the structure is found to be stabilized when the dipole orientation is parallel to the surface of the ZGNR, the height of the lowest atom of the PVDF from the ZGNR is 2.5 Å, and the PVDF lies on the middle position of the ZGNR (Figure 1b,c).

From theoretical³⁰ and experimental^{23,31-33} studies, the dipole orientation of the PVDF is known to depend highly on the kind of substrate. When the substrate is a conductor, the image dipole is induced by the dipole of the PVDF on conducting substrates and the interaction energy between two dipoles should be taken into account. If we regard the PVDF as a single dipole, the energy of perpendicular dipoles is $-2p^2/r^3$ from the dipole-dipole interaction energy equation,³⁰ where pand *r* denote the magnitude of the dipole moment and the distance between the dipole of the PVDF and its image dipole, respectively. On the other hand, the energy of parallel dipoles is $-p^2/r^3$. Thus, on the conducting substrate, the perpendicular dipole direction of the PVDF is energetically favored.^{30,33} On the contrary, in the case of an insulating or semiconducting substrate, for example, KBr³² or KCl,³¹ the dipole is aligned parallel to the surface plane because the image dipole is negligible.³⁰ From the calculations, we find that the PVDF favors lying flat to the ZGNR plane since the ZGNR is semiconducting with its low screening capability.

The distance from the ZGNR to the lowest atom of the PVDF is found to be 2.5 Å, and it is 3.5 Å from the ZGNR to the C–C bond of the PVDF (Figure 1b). From the fully relaxed geometries, we can infer that the PVDF

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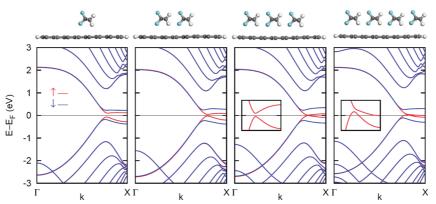


Figure 2. The electronic band structures near the Fermi level. From left to right, the number of PVDF chains is increased from one to four. Because of the potential drop by PVDFs, the band gap of the up-spin decreases and that of the down-spin increases. The red (blue) line denotes the band structure of the up (down)-spin as a function of k. (They overlap in most places.) The inset displays the band structure in the range of $|E - E_F| < 100$ meV and $0.7\pi \le ka \le \pi$. In all figures, the Fermi level (E_F) is set to zero.

weakly binds to the ZGNR and the PVDF affects the electronic structure of the ZGNR not through chemical bonding between the PVDF and the ZGNR, but through the electronic potential induced by the strong dipole moment. The structure shown in Figure 1c, where the C-C bonds of the PVDF and those of the ZGNR cross each other at the middle of the ZGNR, has been found to a ground state. Even if the PVDF deviates its ground state geometry slightly, we find that no essential variation occurs in the electronic structures due to the weak bonding between the PVDF and the ZGNR. It is also noticeable that, with the PVDF, the antiferromagnetic spin configuration of the ZGNR is still more stable than the ferromagnetic one. For a single PVDF on the 8-ZGNR, the interedge antiferromagnetic ordering is more stable by 2.1 meV per edge atom. The isosurface of the charge density difference between the up-spin and the down-spin $(\rho_{\uparrow}(r) - \rho_{\downarrow}(r))$ in this case is presented in Figure 1d.

Now, we analyze the band structure of this joint system, a single PVDF on the 8-ZGNR. The pristine 8-ZGNR shows a small band gap of 0.3 eV for both spins. With one PVDF deposited on the 8-ZGNR, the band structure of the ZGNR is changed as if it were under external transverse electric fields¹¹ (Figure 2). The electric potential energy is raised at the fluorine side and lowered at the hydrogen side of the PVDF. Since the dipole field decays slowly in space, the potential drop induced by this dipole field takes place over a large area which can cover both edges of the ZGNR. The energy eigenvalues of the ZGNR are also modified by this potential variation so that the band gap of the, say, up-spin state is reduced to 0.18 eV, and that of the down-spin state is increased up to 0.41 eV (Figure 2). We can estimate the potential profile generated by a single PVDF chain on the ZGNR by averaging the potential energies in the y-axis with the position of the ZGNR fixed in z direction. Its drop across two edges of the PVDF is 1.2 V and that of the 8-ZGNR is 0.8 V. According to previous works,¹¹ such a band gap change corresponds to the

to the 8-ZGNR, that is, the total potential difference between two edges of the 8-ZGNR is 0.89 V (= 0.05 V/Å \times 17.85 Å, where 17.85 Å is the length of the 8-ZGNR), which agrees reasonably well with the present calculation of 0.8 eV. Thus, the change of the bandgap mainly originates from the potential difference between two edges of the ZGNR. When the electric field is applied, the energy eigenvalues of the states localized on the left side of ZGNRs are pulled up, and those on the right side are pushed down.¹¹ Then, the energy gap of the up-spin state decreases, and that of the down-spin increases. We conclude that the energy eigenvalues of ZGNRs are modified because of interplay between the antiferromagnetic interedge ordering and the dipole field of the PVDF.

case of homogeneous electric field of 0.05 V/Å applied

Before proceeding further, we check the lattice mismatch problem between the PVDF and the ZGNR in the unit cell. As we mentioned before, the lattice of the PVDF is reduced to that of the ZGNR in the y-axis. To verify the effect of the compressed PVDF on the ZGNR, same calculations are performed for a large supercell amounting to 32 unit-cells of the ZGNR and 31 unit-cells of the PVDF, in which the bonds experience almost no strain. Very little change of the band structure is observed with a different width of the PVDF along the periodic direction. Hence, the role of the PVDF is only to generate the electric field by its dipole moment, and the position of the PVDF or the reduced cell size does not appreciably influence the electronic and magnetic properties of the system. In addition, a typical domain size of the ferroelectric thin film of the PVDF is around 200 nm so that, if considering a nanoscale channel device geometry, the effect of phase changes along the PVDF would not be serious in the present case.³³

Next, we increase the number of PVDFs deposited on the 8-ZGNR one by one (Figure 2). Dipole moments of PVDFs are all aligned in the same direction. The total dipole moment of PVDFs is increased, and the potential drop across the ZGNR becomes 1.26, 2.0, and 3.0 V if the number of PVDFs is 2, 3, and 4, respectively, in the 8-ZGNR case. (The local potential drop between two edges of PVDFs increases to 2.1, 3.4, and 5.0 V as increasing the number of PVDFs.) The band gap of the upspin state is decreased while that of the down-spin state increases as the number of PVDFs increase. Eventually, if four PVDFs are coated on the 8-ZGNR, the system turns to a half-metal. The up-spin states cross the Fermi level while the down-spin states still have a band gap of 0.37 eV. Four PVDFs generate enough of a potential difference (3.0 eV) between two edges of the ZGNR to give rise to the half-metallicity of the ZGNR. With low defect concentrations at the edges, the half-metallic nature of ZGNRs is already shown to be robust under the applied external transverse electric field in the previous work.¹¹ Since PVDFs here play the same role as do external fields in ref 11, we note that the induced halfmetallicity of the ZGNRs will occur as long as weak edge defects or imperfections do not alter the magnetic ordering at the edges.

Our calculations indicate that four PVDFs create a potential drop of 3.0 V across the n-ZGNR irrespective of the width (*n* value) of ZGNRs (for $n \ge 8$, tested up to n = 32). The *n*-ZGNR becomes half-metallic when the potential drop across the system generated by PVDFs reaches 3.0 V, which has been suggested to be the critical value for half-metallicity in the previous work.¹¹ In terms of the percentage coverage (i.e., the area of covered PVDFs divided by the area of the ZGNR), the critical value for the transition to half-metal can be calculated by the width of four PVDFs (16.0 Å) divided by the width of the ZGNR (w), 16.0/ $w \times 100$ (%) (w is in angstrom). This can be regarded as a scaling behavior in the PVDF coverage and the width of ZGNRs as follows, similar to the previous study on scaling in the strength of transverse electric fields and the width of the ZGNR¹¹ (Figure 3).

Finally, another advantage of our proposal compared with others lies in the fact that the half-metallic state can return to the insulating state by changing of the dipole orientation of PVDFs. If the dipole direction of PVDFs is set perpendicular to the ZGNR plane by a perpendicular external electric field, as in the usual experiments with back gates, then the potential drop across the ZGNR vanishes and the half-metallicity disappears as well. We have calculated variations of the to-

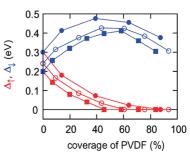


Figure 3. Dependence of half-metallicity on different sizes of the ZGNR and the PVDF. Δ_{\uparrow} (red) denotes the direct bandgap of the up-spin, and Δ_{\downarrow} (blue) denotes the gap of the down-spin as a function of the coverage of PVDFs for the 8-ZGNR (filled circles), 12-ZGNR (open circles), and 16-ZGNR (squares). When the coverage reaches 16.0/w \times 100 (%), where w is the width of the ZGNR in angstrom, the ZGNR becomes half-metallic.

tal energy by rotating a single PVDF on ZGNRs. We have found that, without a perpendicular electric field, the perpendicular dipole direction of the PVDF to the ZGNR is also at the local energy minimum (or quasistable configuration), 30 meV higher than the ground state (the parallel dipole direction). Upon application of perpendicular electric fields, the energy differences between parallel and perpendicular dipole configurations are decreased and eventually, with an electric field of \sim 0.07 V/Å, the perpendicular dipole direction becomes the ground state. An energy barrier for 90° rotation of the PVDF on the ZGNR, that is, parallel to perpendicular direction change, is 96 meV per unit cell without an electric field and decreases to \sim 77 meV with an electric field of 0.07 V/Å. Therefore, it is practically possible to switch between half-metallic and insulating states by applying a perpendicular gate field greater than 0.07 V/Å.

CONCLUSIONS

We have proposed a method to construct the halfmetallic ZGNRs by depositing the ferroelectric material PVDF on them. The PVDFs generate the electrostatic potential on the ZGNR because of their strong dipole moments. When the number of PVDFs coated on ZGNRs increases beyond a critical value, the system becomes half-metallic. The dipole direction of PVDFs is changeable by an external electric field, and switching between half-metallic and insulating states in ZGNRs is made possible.

THEORETICAL METHODS

We performed the first-principle calculations based on the density-functional theory (DFT) within the local spin density approximation (LSDA)³⁴ and spin polarized general gradient approximation (GGA) with the Perdew–Burke–Ernzerhof (PBE) functional,³⁵ respectively, by using the SIESTA package.³⁴ The standard norm-conserving Troullier–Martins pseudopotentials³⁶ were employed, and split-valence double- ζ plus polarization basis³⁴ was used. We have chosen a 400 Ry energy cutoff for a real spacemesh size and 96 *k*-points, uniformly distributed in

the 1D Brillouin zone. All edges were saturated with hydrogen atoms and relaxed by conjugate gradient minimization until the maximum force was less than 0.04 eV/Å. To overcome an intrinsic error due to the pseudoatomic orbital basis set in the weakly binding system, the basis set superposition error (BSSE) was corrected using a counterpoise procedure.^{37,38} In calculations with the PBE functional, we added a pairwise interatomic C₆R⁻⁶ term (E_{vdw}) to the PBE-DFT energy in order to include the van der Waals (vdW) interaction.^{39–41} To obtain accurate vdW energies, the effective C₆ coefficients of each atom in the systems were ob-

tained by using a recent theoretical method exploiting ground state electron density from A. Tkatchencko and M. Scheffler.⁴¹ From the calculation including PBE and vdW corrections, we found that there is no significant difference between atomic and electronic structures based on LDA and those based on PBE and vdW corrections. The comprehensive methods and comparisons are in the Supporting Information. Hence, in the article, all binding energies, relative distances, and orientations between PVDFs and ZGNRs and band structures in the paper are obtained within the LDA calculations.

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Supporting Information Available: Detailed methods and results of the vdW corrected PBE-DFT calculations; comparisons between different calculation methods. This material is available free of charge *via* the Internet at http://pubs.acs.org.

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